

SECRET and
SECRET ORDER RECOMMENDATION BY DEFENSE AGENCY

2-25-04

Application Serial No.: 10/813,284

Defense Agency: ARMY

Filing Date:

Date Referred: 5-11-04

Date Created:

I hereby acknowledge as indicated by my signature on this form that I have inspected this application in administration of 35 USC 181 on behalf of the Agency/Command specified below. I promise not to divulge any information from this application for any purpose other than administration of 35 USC 181.

Recommendation

(e.g. 'Secrecy Not Recommended (SNR)')

Reviewer(s) Signature/Date/Command

W. P. Allen SNR
5-20-04
MAY 19 2004
U.S. Army

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Instructions to Reviewers:

1. All individuals reviewing this application are required under 35 USC 181 to sign and date this form regardless of whether they are making a secrecy order recommendation.

2. The attached copy of the application, any copies made therefrom and this form must be returned to the PTO once a recommendation not to impose secrecy has been made or a secrecy order has been rescinded.

Notice for Completion of Review:

Pursuant to 35 U.S.C. 184, the subject matter of this application may be filed in a foreign country for the purpose of filing a patent application without a license any time after the expiration of 6 months from filing date unless the application becomes the subject of a secrecy order.

3. The PTO will not accept an application for examination if it is determined that the applicant has not complied with the requirements of 35 USC 184. The applicant must file a statement of compliance with the requirements of 35 USC 184 within 6 months from the filing date of the application. The statement must be filed with the application and must be signed by the applicant or the applicant's attorney. The statement must contain the following information: (a) A statement of the applicant's knowledge of the requirements of 35 USC 184. (b) A statement of the applicant's compliance with the requirements of 35 USC 184. (c) A statement of the applicant's intent to file a patent application in a foreign country. (d) A statement of the applicant's intent to file a patent application in the United States. (e) A statement of the applicant's intent to file a patent application in both the United States and a foreign country. (f) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (g) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (h) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (i) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (j) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (k) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (l) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (m) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (n) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (o) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (p) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (q) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (r) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (s) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (t) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (u) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (v) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (w) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (x) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (y) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country. (z) A statement of the applicant's intent to file a patent application in the United States and a foreign country, but not in both the United States and a foreign country.